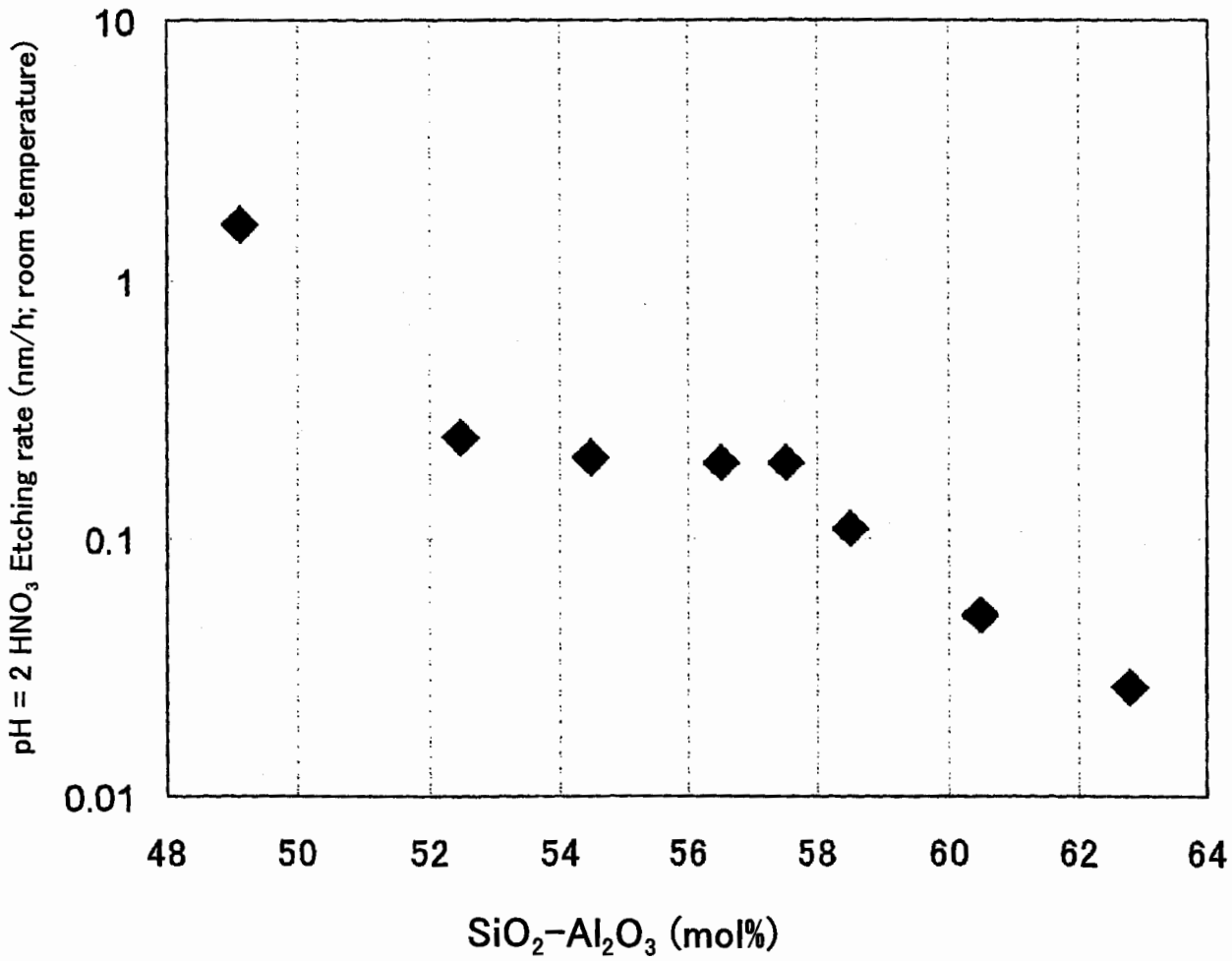
Fig. 1


10
1
0.1
0.01
pH = 2 HNO3 Etching rate (nm/h; room temperature)
48
50
52
54
56
58
60
62
64
SiO2–Al2O3 (mol%)